

INFORMATION DISCLOSURE STATEMENT BY APPLICANT

(use as many sheets as necessary)

Sheet	1	of	1	Application Number	10/588,332
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Complete if Known

Filing Date	March 22, 2007
First Named Inventor	Ines Batinic-Haberle
Art Unit	1624
Examiner Name	Paul V. Ward
Attorney Docket Number	5405-374

FOREIGN PATENT DOCUMENTS

Examiner Initials*	Cite No.	Foreign Patent Document Country Code, Number, Kind Code (if known)	Publication Date MM-DD-YYYY	Name of Patentee or Applicant of Cited Document	Pages, Columns, Lines, Where Relevant Passages or Relevant Figures Appear	T
	1.	JP 02 242860 A	09-27-1990	Toray Industries, Inc.		Ab.
	2.	WO 0/75144 A2	12-14-2000	Trustees of Princeton University		
	3.	CN 1450066 A	10-22-2003	Xianchang Gong		Ab.

NON PATENT LITERATURE DOCUMENTS

Examiner Initials*	Cite No.	Include name of the author (in CAPITAL LETTERS), title of the article (when appropriate), title of the item (book, magazine, journal, serial, symposium, catalog, etc.), date, page(s), volume-issue number(s), publisher, city and/or country where published	T
	4.	WOEHRLE D et al. Metal chelates of porphyrin derivatives as sensitizers in photooxidation of sulphur compounds and in photodynamic therapy of cancer. Izvestia Akademii Nauk SSR. Seria Himiceskaa, Moscow, Russia. January 1, 1994; 12: 2071-2082	Ab.
	5.	GONG X et al. Preparation and characterization of porphyrin nanoparticles. J Am Chem Soc. 2002; 124: 14290-14291	
	6.	GONG X. Large substituent containing porphyrin derivative, its preparation and application as small molecular antioxidant. Chemical Abstracts Service, Columbus, Ohio. October 22, 2003: 3 pp	
	7.	Supplementary European Search Report, EP 05712218.6, mailed May 19, 2010	

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Examiner Signature		Date Considered	
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*EXAMINER: Initial if reference considered, whether or not citation is in conformance with MPEP 609. Draw line through citation if not in conformance and not considered. Include copy of this form with next communication to applicant.